

High throughPut lasER-based processing of Diamond And Silicon (HIPERDIAS)

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Overall presentation of the project



This project has received funding from the European Union's Horizon 2020 research and innovation programme under grant agreement No 687880

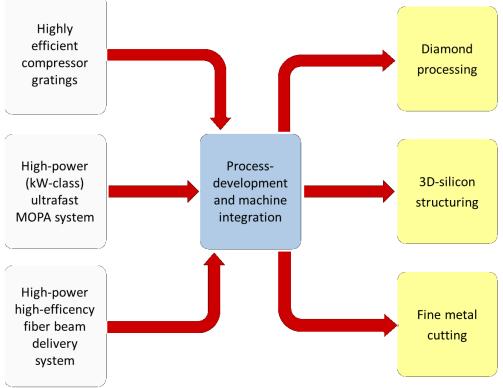


- Call H2020-ICT-27-2015:
 - High-throughput laser-based manufacturing: <u>High-power, high-efficiency laser sources</u> (both continuous wave and <u>pulsed</u>); <u>novel technologies and devices for beam delivery</u> and for processing of multiple beams from laser source arrays; <u>high-performance optical devices and systems</u>; fast <u>synchronisation</u> of laser source and high-speed scanning devices.
 - All RTD actions should address also the related materials, manufacturability, validation of results for the target applications, and standardisation activities, as appropriate. <u>They should demonstrate strong industrial commitment, be</u> <u>driven by user needs</u> and concrete business cases supported by strong exploitation strategies, and cover the value/supply chainas appropriate.





- Brief project overview
 - Project duration: 42 Months
 - Project budget: ~4.4 Mio€ (~3.6 Mio€ from EC + ~0.8 Mio€ fro SNF)





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- Objectives: Applications
 - HIPERDIAS will demonstrate USP laser-based material processing at unprecedented (high-throughput) levels of productivity and precision
 - Three attractive applications shall be investigated to demonstrate the high-throughput laser-based manufacturing:
 - 3D silicon structuring at high-speed: >1mm³/s (~ X10 vs SoA)
 - Precision processing of diamond material : >0.15mm³/s (~ X5-6 vs SoA)
 - Fine cutting of metal for the watch and the medical industry: 500mm/min (~ X2-4 vs SoA)





- Objectives: laser sources and components
 - Flexible high-power CPA-based femtosecond laser sources
 - 50W, 300fs, at 1-2 MHz (system 1: hybrid fiber-bulk amplifer)
 - 200W, 600fs, at 1-2 MHz (system 2: hybrid fiber-bulk amplifier)
 - 500W, 500 fs, 1-2 MHz (system 3: system 1 boosted using a thin-disk multipass amplifier)
 - 1000W, sub-1ps, 1-2 MHz (system 4: system 2 boosted using a thin-disk multipass amplifer)
 - High-power suitable fiber beam delivery (Kagomé fibers)
 - Delivery of >500W (up to 1kW), sub-1ps pulses
 - High-power capable pulse compression gratings
 - >99% diffraction efficiency (per pass) over >5-10 nm spectral bandwidth



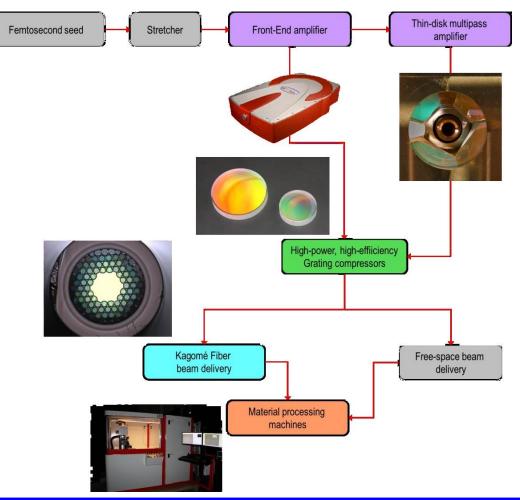


- Objectives: material processing and machine integration
 - Fundamental process development
 - Upscaling for high-throughput
 - Demonstration of productivity increase
 - Integration of system and high-power suitable machines for:
 - 3D silicon ablation
 - Diamond processing and fine-cutting of metal





• Overall of the HIPERDIAS project





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- Work packages
 - WP1: Definition of User Requirements
 - WP2: Process Development
 - WP3: Ultrafast Laser Front-end development
 - WP4: Photonic components for pre- and post-pulse conditioning
 - WP5: Thin-disk multi-pass Booster
 - WP6: System Development
 - WP7: Demonstrators
 - WP8: Exploitation Planning & Dissemination
 - WP9: Project Management





- Deliverables & Milestones
 - 46 Deliverables
 - 45 Milestones

